



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Hiroshi Tayanaka ATTORNEY DOCKET NO. P7,0027
SERIAL NO. 08/818,239 GROUP ART UNIT: 2813
FILING DATE: March 14, 1997 EXAMINER: K. Christiansen
INVENTION: "METHOD FOR MAKING THIN FILM SEMICONDUCTOR,
SOLAR CELL, AND LIGHT EMITTING DIODE"

PRELIMINARY AMENDMENT

Hon. Commissioner of Patents
Washington, D.C. 20231

SIR:

Please enter the following amendment prior to examination of the above-identified patent application.

IN THE CLAIMS

Please add new claims 28-29 as follows:

--28. A method for making a thin film semi-conductor comprising the steps of:
providing a semi-conductor substrate having a surface;
anodizing said semi-conductor substrate at a first current density to provide a first porous layer adjacent said surface having a first porosity;
anodizing said semi-conductor substrate at a second current density higher than said first current density to provide a second porous layer adjacent said first porous layer opposite said surface, said second porous layer having a second porosity greater than said first porosity;
annealing said semi-conductor substrate in a hydrogen atmosphere after said step of anodizing said semi-conductor substrate to provide said second porous layer;
and
forming at least one semi-conductor film on said surface.--

--29. A method for making a thin film semi-conductor comprising the steps of:
providing a semi-conductor substrate having a surface;
forming a first porous layer adjacent said surface having a first porosity;